



#RCE
JW
PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:

MARK B. FUSELIER
DERICK J. WRISTERS
ANDY C. WEI

Examiner: Donghee Kang

Group Art Unit: 2811

Serial No.: 10/821,230

Att'y Docket: 2000.092182/TT5077D

Filed: April 8, 2004

Customer No.: 23720

For: SEMICONDUCTOR DEVICE FORMED
OVER A MULTIPLE THICKNESS
BURIED OXIDE LAYER, AND
METHODS OF MAKING SAME

MAIL STOP RCE

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

CERTIFICATE OF MAILING 37 CFR 1.8

I hereby certify that this correspondence is being deposited with the United States Postal Service with sufficient postage as first class mail in an envelope addressed to: Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450, on September 6, 2005.

May Paul
Signature

REQUEST FOR CONTINUED EXAMINATION UNDER 37 C.F.R. § 1.114

This is a Request for Continued Examination (RCE) of the above-identified application.

1. **Submission required under 37 C.F.R. 1.114**

a. ☒ Previously submitted

i. ☒ Consider the amendment(s)/reply under 37 C.F.R. 1.116 previously filed on July 28, 2005.

ii. ☐ Consider the arguments in the Appeal Brief or Reply Brief previously filed on _____

iii. ☐ Other _____

09/12/2005 MBIZUNES 00000103 010365 10821230

01 FC:1801 790.00 DA

b. ☐ Enclosed

i. ☐ Preliminary Amendment

iii. ☐ Information Disclosure Statement
(IDS)

ii. ☐ Affidavit(s)/Declarations

iv. ☐ Other _____

2. ☐ Fees The RCE fee under 37 C.F.R. 1.17(e) is required by 37 C.F.R. 1.114 when the RCE is filed.

a. ☒ The Director is hereby authorized to charge the following fees, or credit any overpayments, to Advanced Micro Devices, Inc. , Deposit Account No. 01-0365/TT5077D.

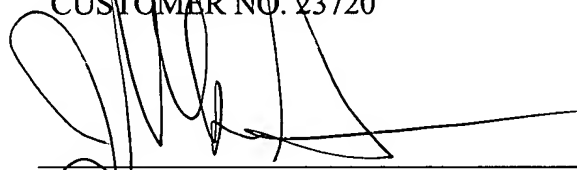
i. ☒ RCE fee required under 37 C.F.R. 1.17(e)

ii. ☐ Extension of time fee (37 C.F.R. 1.136 and 1.17)

iii. ☐ Other:

Respectfully submitted,

WILLIAMS, MORGAN & AMERSON
CUSTOMER NO. 23720



Date: September 6, 2005

J. Mike Amerson
Reg. No. 35,426
10333 Richmond, Suite 1100
Houston, TX 77042
(713) 934-4055
(713) 934-7011

ATTORNEY FOR APPLICANTS